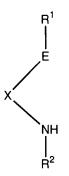
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What is claimed is:

- 1. A composition comprising
 - (1) a ligand characterized by the following general formula:

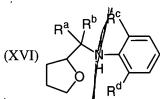


wherein, E is selected from O, S, Se, Te; each R¹ and R² is independently selected from the group consisting of hydrogen, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heteroalkyl, heterocycloalkyl, substituted heteroalkyl, substituted heteroaryl, substituted heteroaryl, alkoxyl, aryloxyl, silyl, boryl, phosphino, amino, thio, seleno, and combinations thereof; X is any covalent bridging moiety provided that X is not a benzylic bridge where the benzylic carbon atom is bound to the NHR² fragment and optionally, R¹ and/or R² may joined together with X in a ring structure;

- (2) a metal precursor compound characterized by the general formula M(L)_n where M is a metal selected from Groups 3, 4 and the lanthanides; L is independently selected from the group consisting of halide, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heterocycloalkyl, substituted heterocycloalkyl, substituted aryl, heteroaryl, substituted heteroaryl, alkoxy, aryloxy, hydroxy, boryl, silyl, amino, amine, hydrido, allyl, diene, seleno, phosphino, carboxylates, thio, 1,3-dionates, oxalates, carbonates, nitrates, sulphates, and combinations thereof; n is 1, 2, 3, 4, 5, 6, 7, 8, or 9; and
 - (3) optionally, at least one activator;

with the provisio that when M is zirconium, then the ligand is not a compound according to formula XVI:





wherein each R^a and R^b are each indefendently selected from the group consisting of alkyl, aryl, substituted aryl, heteroaryl, substituted heteroaryl and hydrogen; and R^c and R^d are each independently selected from the group consisting of alkyl, aryl and hydrogen.

- 2. The composition of Claim 1, with the further proviso that M is not zirconium when R¹ and X are joined together in a ring structure.
- 3. The composition of Claim 1 in which the ligand is not a compound according to structure (IIa) or (IIb), where M' is zirconium. 10
 - 4. The composition of Claim 1 in which the ligand is not a compound according to structure (IIa) or (IIb).
- 5. The composition of Claim 1 in which the ligand is a compound according to 15 formulae (III), (IV), (V), (VI), (VIII), (VIII), (IX) (X) and (XI).
 - The composition of Claim 5 in which the metal precursor is substantially pure 6. with respect to the metal.
 - 7. The composition of Claim 6 in which the metal is hafnium.
 - A composition comprising a ligand characterized by formula (III), (IV), (V), 8. (VI), (VII), (VIII), (IX), (X) of (XI);
- a metal precursor compound characterized by the general formula M(L)_n where M 25 is hafnium; L is independently selected from the group consisting of halide, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heteroalkyl heterocycloalkyl, substituted heterocycloalkyl, aryl, substituted aryl, heteroaryl, substituted heteroaryl, alkoxy, aryloxy, hydroxy, boryl, silyl, amino,

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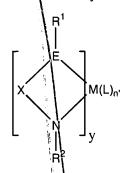
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amine, hydrido, allyl, diene, seleno, phosphino, carboxylates, thio, 1,3-dionates, oxalates, carbonates, nitrates, sulphates, and combinations thereof; n is 1, 2, 3, 4, 5, 6, 7, 8, or 9; and

optionally, at least one activator.

9. The composition of Claim 8 in which the metal precursor compound is about 90% or more pure with respect to the metal.

10. A metal ligand complex characterized by the following formula:



wherein, E is selected from O, S, Se, Te; each R¹ and R² is independently selected from the group consisting of hydrogen, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heteroalkyl, heterocycloalkyl, substituted heteroaryl, substituted heteroaryl, alkoxyl, aryloxyl, silyl, boryl, phosphino, amino, thio, seleno, and combinations thereof; X is any covalent bridging moiety provided that X is not a benzylic bridge where the benzylic carbon atom is bound to the NHR² fragment; and optionally, R¹ and/or R² may joined together with X in a ring structure. M is a metal selected from Groups 3, 4 and the lanthanides; L is a ligand which is independently selected from the group consisting of halide, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heteroalkyl heterocycloalkyl, substituted heterocycloalkyl, aryl, substituted aryl, heteroaryl, substituted heteroaryl, alkoxy, aryloxy, hydroxy, boryl, silyl, amino, amine, hydrido, allyl, diene, seleno, phosphino, carboxylates, thio, 1,3-dionates, oxalates, carbonates, nitrates, sulphates, and combinations thereof; n' is 1, 2, 3, 4, 5, 6; and when M is a Group 3 or lanthanide metal, y may be 1 or 2; and

11. The metal ligand complex of Claim 10 with the proviso that when E is O and R¹ and X are joined together in a non-aromatic ring structure, then M is other than zirconium.

12. The metal ligand complex of Claim 10 with the proviso that when R¹ and X are joined together in a ring structure, then M is other than zirconium.

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13. The metal ligand complex of Claim 10 which is not characterized by the formula (XVIII) where M' is zirconium.

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14. The metal ligand complex of Claim 10 which is characterized by a formula selected from the group consisting of (XIX), (XX), (XXI), (XXXI), (XXXII), (XXXIV) and (XXXV).

15. The metal ligand complex of Claim 10 which is substantially pure with respect to the metal.

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16. The metal ligana complex of Claim 15 in which the metal is hafnium.

17. A metal ligand complex which is characterized by either of the following formulae:



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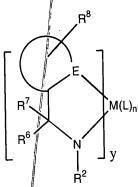
$$R^{4}$$
 R^{3}
 N
 y
 R^{2}
 XIX
 XIX

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wherein, E is selected from O, S, Se, Te; each R and R² is independently selected from the group consisting of hydrogen, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heterocycloalkyl, substituted heterocycloalkyl, substituted heterocycloalkyl, substituted heterocycloalkyl, aryl, substituted aryl, heteroaryl, substituted heteroaryl, alkoxyl, aryloxyl, silyl, boryl, phosphino, amino, thio, seleno, and combinations thereof; M is a metal selected from Groups 3, 4 and the lanthanides; and L is independently chosen from the group consisting of halide, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heterocycloalkyl, substituted heterocycloalkyl, substituted heterocycloalkyl, substituted heteroaryl, substituted heteroaryl, alkoxy, aryloxy, hydroxy, boryl, silyl, amino, hydrido, allyl, diene, seleno, phosphino, carboxylates, thio, 1,3-dionates, oxalates, carbonates, nitrates, sulphates, and combinations thereof; y is 1, 2 or 3; and n is 1, 2, 3, 4, 5, 6.

18. A metal ligand complex characterized by the following formula:



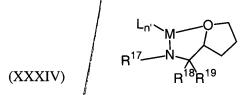
where M is hafnium; E is selected from the group consisting of O, S, Se, and Te; y is 1, 2 or 3; n' is 1, 2, 3, 4, 5, 6; R², R⁶ and R⁷ are each independently selected from the group consisting of hydrogen, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heteroalkyl, heteroayl, substituted heteroayl, substituted heteroayl, alkoxyl, aryloxyl, silyl, boryl, phosphino, amino, thio, seleno, and combinations thereof; and each R⁸ is independently selected from the group alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heteroayl, substituted heteroayl, substituted heteroayl, substituted heteroayl, substituted heteroayl, substituted heteroayl,

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alkoxyl, aryloxyl, silyl, boryl, phosphino, amino, thio, seleno, and combinations thereof.

19. The metal ligand complex of Claim 18 characterized by the following formula:



wherein R¹⁷ is aryl or substituted aryl; R¹⁷ and R¹⁸ are independently hydrogen, alkyl, substituted alkyl or aryl; and M, L and n' are as previously defined.

- 20. A metal ligand complex characterized by a formula selected from the group consisting of (XIX), (XX), (XXI), (XXXI), (XXXII), (XXXIII), (XXXIII), (XXXIV), and (XXXV) in which M is hafnium.
- 15 21 The metal ligand complex of Claim 20 which is substantially pure with respect to the hafnium.
 - 22. A polymerization reaction or process employing a composition according to Claim 1.
 - A polymerization reaction or process employing a composition according to Claim 2.
- 24. A polymerization reaction or process employing a composition according to Claim 3.
 - 25. A polymerization reaction or process employing a composition according to Claim 4.

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26. A polymerization reaction or process employing a composition according to Claim 5.

27. A polymerization reaction or process employing a composition according to Claim 6.

28. A polymerization reaction or process employing a composition according to Claim 7.

29. A polymerization reaction or process employing a composition according to Claim 8.

30. A polymerization reaction or process employing a composition according to Claim 9.

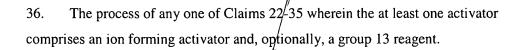
31 A polymerization reaction or process employing a metal ligand complex according to Claim 10.

20 32. A polymerization reaction or process employing a metal ligand complex according to Claim 17.

33. A polymerization reaction or process employing a metal ligand complex according to Claim 18.

34. A polymerization reaction or process employing a metal ligand complex according to Claim 20.

35. A polymerization reaction or process employing a metal ligand complex according to Claim 21.



- 37. The process of any of Claims 22/35 wherein the at least one activator comprises an ion forming activator and optionally, a divalent reagent.
 - 38. The process of any one of Claims 22-35 wherein the at least one activator comprises an ion forming activator and, optionally, an alkali metal reagent.

39 40. 10 A process for catalytically polymerizing a monomer comprising subjecting the monomer to polymerization conditions in the presence of a catalyst composition, wherein said catalyst composition comprises a metal ligand complex according to any one of Claims 1, 8, 16-18 and 20.

40 The process of Claim 40 wherein said at least one monomer is an olefin, 41. diolefin or acetylenically unsaturated compound.

A process for polymerizing a monomer, comprising providing a reactor, 42. providing at least one monomer to said reactor and providing a composition or 20 catalyst to said reactor, wherein said composition or catalyst is defined as in any one of Claims 1, 8, 16-18 and 20 and subjecting said reactor contents to polymerization conditions.

43'. The process of claim 42 wherein said at least one monomer is an olefin, 25 diolefin or acetylenically unsaturated compound.

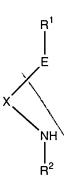
44. An array of compounds wherein each compound of the array is different from the other compounds of the array, and there are at least 8 compounds in the array, wherein each of the compounds is characterized by the general formula:

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W

W2

'nЗ



wherein, E is selected from O, S, Se, Te; each R¹ and R² is independently selected from the group consisting of hydrogen, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heteroalkyl, substituted heteroalkyl, heterocycloalkyl, substituted heteroaryl, substituted heteroaryl, alkoxyl, aryloxyl, silyl, boryl, phosphino, amino, thio, seleno, and combinations thereof; X is any covalent bridging moiety excluding a benzylic bridge where the benzylic carbon atom is bound to the NHR² fragment; and optionally, R¹ and/or R² may joined together with X in a ring structure.

45. UQThe array of claim 44, wherein each compound additionally comprises a metal precursor M(L)_n where M is a transition metal or main group metal or lanthanide metal and L is independently each occurrence selected from the group consisting of halide, alkyl, substituted alkyl, cycloalkyl, substituted cycloalkyl, heterocycloalkyl, substituted heterocycloalkyl, cyclopentadienyl, substituted cyclopentadienyl, aryl, substituted aryl, heteroaryl, substituted heteroaryl, alkoxy, aryloxy, hydroxy, boryl, silyl, hydride, thio, seleno, phosphino, amino, amine, carboxylates, 1,3-dionates, oxalates, carbonates, nitrates, sulfates, perchlorates, sulfonates phosphonates and combinations thereof; and n is an integer from 1-9.